

(12) INTERNATIONAL APPLICATION PUBLISHED UNDER THE PATENT COOPERATION TREATY (PCT)

(19) World Intellectual Property
Organization
International Bureau

(43) International Publication Date
06 March 2025 (06.03.2025)



(10) International Publication Number
WO 2025/049233 A1

- (51) **International Patent Classification:**
C25D 21/06 (2006.01) C25D 21/18 (2006.01)
- (21) **International Application Number:**
PCT/US2024/043390
- (22) **International Filing Date:**
22 August 2024 (22.08.2024)
- (25) **Filing Language:** English
- (26) **Publication Language:** English
- (30) **Priority Data:**
63/578,955 25 August 2023 (25.08.2023) US
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(81) **Designated States** (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CV, CZ, DE, DJ, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IQ, IR, IS, IT, JM, JO, JP, KE, KG, KH, KN, KP, KR, KW, KZ, LA, LC, LK, LR, LS, LU, LY, MA, MD, MG, MK, MN, MU, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU, RW, SA, SC, SD, SE, SG, SK, SL, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, WS, ZA, ZM, ZW.

(84) **Designated States** (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, CV, GH, GM, KE, LR, LS, MW, MZ, NA, RW, SC, SD, SL, ST, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, RU, TJ, TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, ME, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, KM, ML, MR, NE, SN, TD, TG).

Published:
— with international search report (Art. 21(3))

(54) **Title:** FILTERING A DRAIN PATH IN AN ELECTRODEPOSITION TOOL

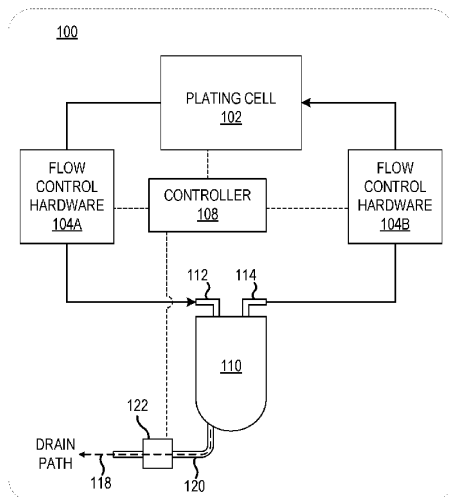


FIG. 1

(57) **Abstract:** Examples are disclosed that relate to the use of screens in electrodeposition tools to protect drain components from debris. One example provides an electrodeposition tool. The electrodeposition tool comprises a filter bowl. The filter bowl comprises an inlet and an outlet. The filter bowl further comprises a filter interface configured to position a filter along a fluidic path between the inlet and the outlet. The filter bowl further comprises a drain opening positioned to drain an inlet side of the filter bowl when the filter is positioned in the filter interface. The electrodeposition tool further comprises a drain path leading from the drain opening, the drain path comprising a drain component. The electrodeposition tool further comprises a screen for filtering debris from the electroplating solution, wherein the screen is disposed within a fluidic path between the inlet and the drain component.

WO 2025/049233 A1